

an organic EL layer formed above each of the first and second set of electrodes;
an effectively optical area in which the first set of electrodes is formed;
a dummy area disposed around the effectively optical area, in which the second set of electrodes is formed; and
a bank layer disposed between each of the first and second set of electrodes, the organic EL layer in the dummy area being disposed on a layer made of a same material as the bank layer.

16. (Twice Amended) The organic EL device according to claim 13, the bank layer including an organic bank layer, the organic EL layer in the dummy area being disposed on a layer made of a same material as the organic bank layer.

17. (Twice Amended) An organic EL device, comprising:
a first and second set of electrodes;
an organic EL layer formed above each of the first and second set of electrodes;
an effectively optical area in which the first set of electrodes is formed; and
a dummy area disposed around the effectively optical area, in which the second set of electrodes is formed, the organic EL layer in the dummy area being disposed on a layer made of a same material as the electrodes.

18. (Twice Amended) The organic EL device according to claim 17, further including a bank layer being formed laterally between portions of the organic EL layer in the dummy area.

19. (Twice Amended) An organic EL device, comprising:
a first and second set of electrodes;

an organic EL layer formed above each of the first and second set of electrodes;
 an effectively optical area in which the first set of electrodes is formed; and
 a dummy area disposed around the effectively optical area, in which the second set of electrodes is formed, adjacent portions of the organic EL layer being disposed at a constant pitch in both the effectively optical area and the dummy area.

21. (Twice Amended) An organic EL device, comprising:

an effectively optical area having a first and second set of electrodes; and
 an organic EL layer formed on each of the first and second set of electrodes,
 wherein the organic EL layer being formed both on areas supposed to be the effectively optical area and on other areas not over the first set of electrodes, which are outside the effectively optical area.

22. (Twice Amended) An organic EL device, comprising:

an effectively optical area having a first and second set of electrodes; and
 an organic EL layer formed above each of the first and second set of electrodes, wherein the organic EL layer being formed in areas not having the first set of electrodes and which are supposed to be the effectively optical area.

Please add new claims 24-38 as follows:

--24. An EL device comprising:

an optically active area including a plurality of pixels,
 a first EL layer disposed in the optically active area;
 a dummy area including a dummy pixel, which substantially does not relate to display, being adjacent to the optically active area;
 a second EL layer disposed in the dummy area.--

--25. An EL device according to claim 24, further comprising a bank that divides the optically active area into the plurality of pixels.--

--26. An EL device according to claim 25, wherein the bank is formed in the dummy area,

wherein the first EL layer is provided in a region partitioned by the bank, and wherein the second EL layer is provided on the bank in the dummy area.--

--27. An EL device according to claim 25, wherein the bank includes a plurality of layers.--

--28. An EL device according to claim 25, further comprising a electrode in an area partitioned by the bank, the first EL layer being provided on the electrode.--

--29. An EL device according to claim 27, wherein the bank includes at least a SiO₂ layer and a polyimide layer.--

--30. An EL device according to claim 26, wherein the bank is formed in the dummy area, and the bank divides the dummy area into a plurality of dummy pixels.--

--31. An EL device according to claim 30, the second EL layer is provided in the area partitioned by the bank.--

--32. An EL device according to claim 31, wherein the bank includes at least a SiO₂ layer and a polyimide layer,

wherein the dummy pixels are divided by the polyimide layer, and

wherein the second EL layer is disposed on the SiO₂ layer.--

--33. An EL device according to claim 24, further comprising:
a substrate where the plurality of pixels and dummy pixel;
a circuit element portion including a TFT, and provided between the first EL layer and the substrate; and